



# **Features: Advanced Cluster Management for Kubernetes on Red Hat OpenShift with NetApp**

NetApp Solutions

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# Features: Advanced Cluster Management for Kubernetes on Red Hat OpenShift with NetApp

## Create resources on multiple clusters

Advanced Cluster Management for Kubernetes allows users to create resources on one or more managed clusters simultaneously from the console. As an example, if you have OpenShift clusters at different sites backed with different NetApp ONTAP clusters, and want to provision PVC's at both sites, you can click the **+** sign on the top bar. Then select the clusters on which you want to create the PVC, paste the resource YAML, and click **Create**.

### Create resource

[Cancel](#)[Create](#)

Clusters | Select the clusters where the resource(s) will be deployed.

2 x local-cluster,  
ocp-vmw

Resource configuration | Enter the configuration manifest for the resource(s).

YAML

```
1 kind: PersistentVolumeClaim
2 apiVersion: v1
3 metadata:
4   name: demo-pvc
5 spec:
6   accessModes:
7     - ReadWriteOnce
8   resources:
9     requests:
10      storage: 1Gi
11   storageClassName: ocp-trident
```

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